

3-Day PLD Course

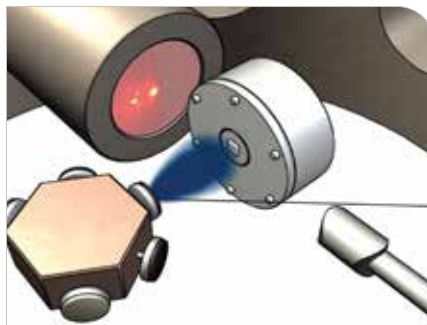
ADVANCED PULSED LASER DEPOSITION OF COMPLEX OXIDES

Twente Solid State Technology organises an annual course in collaboration with Coherent, STAIB, the Inorganic Materials Science (IMS) group and the MESA+ Institute for Nanotechnology. Goal of the course is to obtain an understanding of the scientific and technological background of Pulsed Laser Deposition (PLD) controlled by high pressure RHEED, including hands-on training.

PARTICIPANTS WILL OBTAIN

Understanding of the fundamental and technological background of thin film growth and growth parameter optimisation in pulsed laser deposition controlled by high pressure RHEED.

Experimental skills regarding all relevant facets of a typical pulsed laser deposition growth experiment, including substrate treatment, optics and laser spot alignment, target preparation and optimisation of RHEED parameters in a typical growth experiment.



Tuesday
June 13th 2023
till Thursday
June 15th 2023

**At TSST and MESA+
Institute for Nano-
technology
Enschede,
The Netherlands**

►► Upon completion of the
full program participants
will be granted a Certificate
of Attendance ◀◀

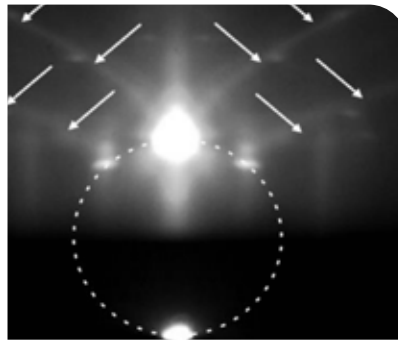


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WORKING METHODS

The course will be conducted in English and is divided into three main sections:

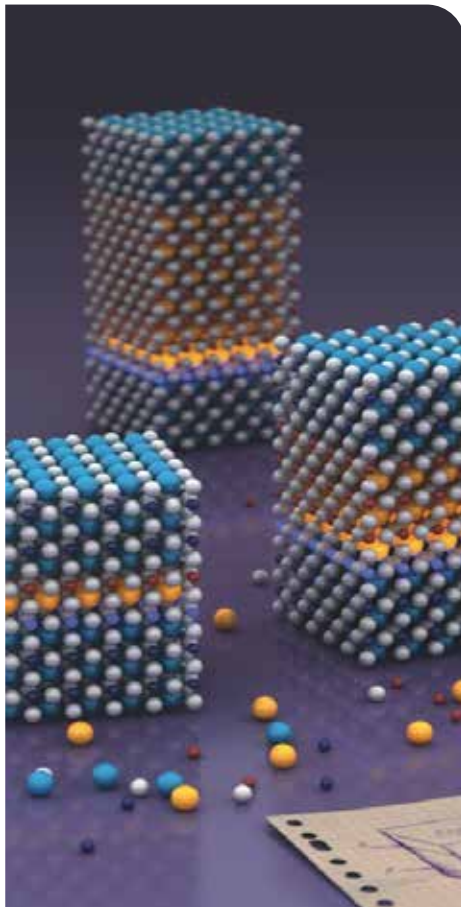
- **THEORY:**
participants are given profound introductions to the theoretical background of RHEED controlled thin film growth with PLD.
- **HANDS-ON TRAINING:**
the knowledge is deepened during hands-on training on state-of-the-art PLD systems.
- **TOPICS OF INTEREST:**
the course concludes with an open discussion on topics submitted by the participants.



Rijnders, University of Twente



Pulsed Laser Deposition has made a tremendous progress during the last decades in the fabrication of (complex) materials, including oxide thin films. The development of high pressure RHEED has lead to an improved control over single crystal surface termination and growth on atomic level, as well as new growth manipulation techniques like pulsed laser interval deposition. At present, highly epitaxial growth and atomically sharp interfaces are achieved in the growth of complex oxide heterostructures.



COURSE CONTENT

- Principles of PLD including plasma plume characteristics and growth kinetics.
- Thin film growth experiment, preparation, oxide substrate treatment, including chemical etching and heat treatment of perovskite substrates.
- Principles of high-pressure RHEED, filament exchange, e-beam optimization, RHEED intensity measurements during thin film growth experiments.

INCLUDED:

- 3 lunches, 2 dinners
- Overnight stay in hotel from Monday June 12th till Thursday June 15th 2023
- Social event

Costs: €2.000,- (excl. VAT)

For information and registration, please contact us at info@tsst.nl



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